ATTY DOCKET NO. Form PTO 1449 SERIAL NO. U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE 211810US99 09/911,495 0118 **APPLICANT** LIST OF REFERENCES CITED BY APPLICANT BARBARA F. BARENBURG ET AL **GROUP** FILING DATE FE8 0 6 2002 2813 JULY 25, 2001 **U.S. PATENT DOCUMENTS** DOCUMENTADEN SUB FILING DATE **EXAMINER CLASS** DATE NAME IF APPROPRIATE **CLASS** INITIAL NUMBER 5B6 AA4,174,422 11/13/79 Matthews et al. Sp 6 4,523,211 06/11/85 Morimoto et al. AB 506 AC 4,661,176 04/28/87 Manasevit 4,793,872 12/27/88 Meunier et al. 1B6 ΑD 506 ΑE 4,855,249 08/08/89 Akasaki et al. AF 03/27/90 5 B 0 4,912,087 Aslam et al 5 BG 5,173,474 12/22/92 Connell et al. AG AΗ 5.358.925 10/25/94 Neville Connell et al. 566 ΑI 5,393,352 02/28/95 Summerfelt 500 506 ΑJ 5,418,216 05/23/95 Fork 566 ΑK 5,450,812 09/19/95 McKee et al. AL 5,478,653 12/26/95 Guenzer 555 McKee et al. 300 AM 5,482,003 01/09/96 ΑN 5,514,484 05/07/96 Nashimoto 536 ΑO 5,588,995 12/31/96 Sheldon 5 BG ΑP 03/31/98 Fork et al. SBL 5,733,641 596 AQ 5,830,270 11/03/98 McKee et al. 500 AR 5,912,068 06/15/99 Jia 533 Wollesen 02/01/00 AS 6.020.222 306 AT 6,064,092 05/16/00 Park 586 ΑU 6,096,584 08/01/00 Ellis-Monaghan et al. SOU ΑV 10/24/00 So 6,136,666 AW 01/16/01 536 6.174.755 Manning 536 AX6,180,486 01/30/01 Leobandung et al. 536 ΑY 3,802,967 04/09/74 Ladany et al. 09/13/83 3 CG ΑZ 4,404,265 Manasevit 3BG ВА 4,482,906 11/13/84 Hovel et al. 506 BB 4,846,926 07/11/89 Kay et al. ВС 01/02/90 Shastry 536 4,891,091 550 BD 4,928,154 05/22/90 Umeno et al ΒE 4,963,949 10/16/90 Wanlass et al. 566 5,141,894 08/25/92 Bisaro et al. 586 BF 326 10/27/92 Calviello et al BG 5,159,413 30 G BH 5,221,367 06/22/93 Chisholm et al 536 ВΙ 5,225,031 07/06/93 McKee et al. 1BG BJ 5,556,463 09/17/96 Guenzer 5,670,798 09/23/97 Schetzina SGO BK 526 BL 5,735,949 04/07/98 Mantl et al. 536 вм 5,741,724 04/21/98 Ramdani et al. BN 536 5,810,923 09/22/98 Yano et al. BO 6,045,626 04/04/00 5 B 6 Yano et al. BP 6,064,078 05/16/00 Northrup et al. 5BG 6,103,008 08/15/00 McKee et al.

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ATTY DOCKET NO. SERIAL NO. U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE Form PTO 1449 09/911,495 211810US99 **APPLICANT** LIST OF REFERENCES CHED BY APPLICANT BARBARA F. BARENBURG ET AL GROUP FILING DATE FEB 0 6 2002 JULY 25, 2001 2813 **U.S. PATENT DOCUMENTS** NUMBER NUMBER SUB FILING DATE **EXAMINER** DATE **CLASS** NAME IF APPROPRIATE **CLASS** INITIAL CA 6,107,653 08/22/00 Fitzgerald 536 CB 6,113,690 09/05/00 Yu et al. 536 CC 500 6,143,072 11/07/00 McKee et al. CD 5,155,658 10/13/92 Inam et al. 566 CE 09/28/93 Ramesh 5,248,564 5B6 CF 5 B 6 5,270,298 12/14/93 Ramesh CG 5,418,389 05/23/95 Watanabe 5 BG 386 СН 6,055,179 04/25/00 Koganei et al. CI 5,326,721 07/05/94 Summerfelt 576 Oishi et al. 5B6 CJ 5,310,707 05/10/94 506 CK 4,999,842 03/12/91 Huang et al. 5,874,860 536 CL 02/23/99 Brunel et al. CM 6,002,375 12/14/99 Corman et al. 555 536 01/31/89 Thornton et al CN 4,802,182 CO 4,284,329 08/18/81 Smith et al. 3B (-516 CP 02/08/77 Andringa 4,006,989 535 CQ 5,729,641 03/17/98 Chandonnet et al. 06/17/97 CR 5,640,267 May et al. SBE 5,576,879 11/19/96 Nashimoto 5 BG CS СТ 535 5,528,414 06/18/96 Oakley 5 B U CU 4,802,182 01/31/89 Thornton et al. 07/25/95 Dijaii et al. 206 CV 5,436,759 CW 10/03/00 336 6,128,178 Newns CX 6,121,642 09/19/00 Newns 3BG 5 B G CY 5,926,496 07/20/99 Ho et al. 08/04/98 5,790,583 Ho CZ 356 DA 536 5,825,799 10/20/98 Ho et al. 356 DB 5,857,049 01/05/99 Beranek et al. 02/06/01 DC 6,184,144B1 Lo 1B6 300 DD 5,981,400 11/09/99 Lo DΕ 5,286,985 02/15/94 Taddiken 506 3130 10/16/73 Walther DF 3,766,370 500 DG 10/11/98 Shahan et al. 4,777,613 386 DH 5,990,495 11/23/99 Ohba 536 DΙ 5,081,062 01/14/92 Vasudev et al. 536 DJ 5,404,581 04/04/95 Honjo 566 4,896,194 01/23/90 Suzuki DK 306 DL 5,606,184 02/25/97 Abrokwah, et al. 536 Abrokwah, et al. DM 5,060,031 10/22/91 5 B G 09/05/00 DN 6,114,996 Nghiem 4,882,300 11/21/89 58G DO Inoue et al. SBG DP 5,674,366 10/07/97 Hayashi et al. 01/16/01 | Conrad 6,173,474

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586	EA	5,731,220	03/24/98	Tsu et al.			
536	EB	5,828,080	10/27/98	Yano et al.			
336	EC	5,801,105	09/01/98	Yano et al.			·-
336	ED	4,484,332	11/20/84	Hawrylo	-		
5136	EE	4,815,084	03/21/89	Scifres et al.			
506	EF	5,293,050	03/08/94	Chapple-Sokol et al			
335	EG	6,222,654	04/24/01	Frigo			
5 B C-	EH	5,937,285	08/10/99	Abrokwah et al.			
336	ΕI	5,116,461	05/26/92	Lebby et al.			
335	EJ	5,640,267	06/17/97	May et al.	_		
300	EK	5,442,191	08/15/95	Ма	<u> </u>		
536	EL	6,008,762	12/28/99	Nghiem			·
536	EM	5,444,016	08/22/95	Abrokwah, et al.			
136	EN	5,614,739	03/25/97	Abrokwah et al.	_		
306	EO	5,480,829	01/02/96	Abrokwah, et al.			
386	EP	5,144,409	09/01/92	Ма	—		
5,36	EQ	6,058,131	05/02/00	Pan			
536	ER	5,995,359	11/30/99	Klee et al.			
5B6	ES	6,146,906	11/14/00	Inoue et al.			
586	ET	6,180,252 B1	01/30/01	Farrell et al.			
336	EV	4,876,219	10/24/89	Eshita et al.			
586	EW	5,391,515	02/21/95	Kao et al.	-		
3B&	EX	4,963,508	10/16/90	Umeno et al.			
506-	EY	5,063,166	11/05/91	Mooney et al.			
500		5,356,831		Calviello et al.	 		
366	FA	5,777,762	07/07/98	Yamamoto			
530	FB	5,778,116	07/07/98	Tomich	—		
5BG	FC	5,127,067	06/30/92	Delcoco et al.			
306	FD	5,861,966	01/19/99		ļ ,		
830	FE	6,137,603	10/24/00	Henmi			
53G	FF	5,858,814		Goossen et al.	 		
308	FG	5,778,018	07/07/98	Yoshikawa et al.	1		
5 B G	FH	5,764,676	06/09/98	Paoli et al.			
5 BG	FI	5,729,394	03/17/98	Sevier et al.			
300	FJ	5,883,996		Knapp et al.	 		
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LIST OF REFERENCES CITED BY A PLICANT			ICANT	BARBARA F. BARENBURG ET AL		
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300	AAJ	10-321943	12/04/98	Japan		
>30	AAK	11-238683	08/31/99	Japan	X	
538	AAL	11-260835	09/24/99	Japan w/English Abstract	x	
>6C		HEI 2-391	01/05/90	Japan w/English Abstract	X	
745		5-48072	02/26/93	Japan w/English Abstract	X	
335		52-88354	07/23/77	Japan	×	
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505	-	55-87424	07/02/80	Japan	х	
506	AAR	61-108187	05/26/86	Japan w/English Abstract	X	
566	AAS	6-232126	08/19/94	Japan	×	
350	AAT	6-291299	10/18/94	Japan w/English Abstract	X	
3 3b	AAU	63-34994	02/15/88	Japan w/English Abstract	X	
586	AAV	63-131104	06/03/88	Japan w/English Abstract	X	
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356	AAZ	WO 99/63580	12/09/99	WIPO	X	
330	BAA	WO 99/14804	03/25/99	WIPO	X	
300	ввв	WO 97/45827	12/04/97	WIPO		
SBL	ввс	WO 99/19546	04/22/99	WIPO		
5 BC-	BBD	WO 00/33363	06/08/00	WIPO		
336	BBE	WO 00/48239	08/17/00	WIPO		
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LISTOF	REFE	RENCES CITED BY APPLICANT	APPLICANT BARBARA E B	<u> </u>			
·		LEB 0 6 5005	FILING DATE JULY 25, 2001	GROUP 2813			
	OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.)						
200-	CAA	Nakagawara et al., "Effects of Buffer Layers in Epitaxial Growth of SrTiO ₃ Thin Film on Si(100), <i>J. Appl. Phys.</i> , 78 (12), A December 15, 1995, pp. 7226-7230.					
SB6-	СВВ	Suzuki et al., "A Proposal of Epitaxial Oxide Thin Film Structures For Future Oxide Electronics," <i>Materials Science and Engineering B41</i> , (1996), pp. 166-173.					
190	ccc	W. F. Egelhoff et al., "Optimizing GMR Spin Valves: The Outlook for Improved Properties", 1998 Int'l Non Volatile Memory Technology Conference, pp. 34-37.					
350	CCD	Wang et al., "Processing and Performance of Piezoelectric Films", Univ. Of MD, Wilcoxon Research Col, and Motorola Labs, May 11, 2000.					
530	CCE	M. Rotter et al., "Nonlinear Acoustoe August 16, 1999, pp. 965-967.	lectric Interactions in GaAs/LiNbO ₃ Struct	tures", Applied Physics Letters, Vol. 75(7),			
SET	CCF	K. Sreenivas et al., "Surface Acoustic Wave Propagation on Lead Zirconate Titanate Thin Films," Appl. Phys. Lett. 52 (9), Feb. 29, 1998, pp. 709-711.					
306	ccg	M. Rotter et al., "Single Chip Fused Hybrids for Acousto-Electric and Acousto-Optic Applications," 1997 Applied Physics Letters, Vol. 70(16), April 21, 1997, pp. 2097-2099.					
300	ссн	A. Mansingh et al., "Surface Acoustic Wave Propagation in PZT/YBCO/SrTiO ₃ and PbTiO ₃ /YBCO/SrTiO ₃ Epitaxial Heterostructures," <i>Ferroelectric</i> , Vol. 224, pages 275-282, 1999.					
SBC	CCI	S. Mathews et al., "Ferroelectric Field Effect Transisitor Based on Epitaxial Perovskite Heterostructures", Science, Vol. 276, April 11, 1997, pp. 238-240.					
SBL	CCJ	R. Houdre et al., "Properties of GaAs on Si Grown by Molecular Beam Epitaxy," Solid State and Materials Sciences, Vol. 16, Issue 2, 1990, pp. 91-114.					
S 156	ССК	S. F. Fang et al., "Gallium Arsenide and Other Compound Semiconductors on Silicon," J. Appl. Phys., 68(7), October 1, 1990, pp. R31-R58.					
Sal	CCL	Carlin et al., "Impact of GaAs Buffer Thickness on Electronic Quality of GaAs Grown on Graded Ge/GeSi/Si Substrates, Appl. Phys. Letter, Vol. 76, No. 14, April 2000, pp. 1884-1886.					
JG 6-	ССМ	Ringel et al., "Epitaxial Integration of III-V Materials and Devices with Si Using Graded GeSi Buffers," 27 th International Symposium on Compound Semiconductors, Oct. 2000.					
430°	CCN	Zogg et al., "Progress in Compound-Semiconductor-on-Silicon-Heteroepitaxy with Fluoride Buffer Layers," <i>J. Electrochem Soc.</i> , Vol. 136, No. 3, March 1998, pp. 775-779.					
500°	ссо	Xiong et al., "Oxide Defined GaAs Vertical-Cavity Surface-Emitting Lasers on Si Substrates," <i>IEEE Photonics Technology Letters</i> , Vol. 12, No. 2, Feb. 2000, pp. 110-112.					
186	ССР	Clem et al., "Investigation of PZT//LSCO//Pt//Aerogel Thin Film Composites for Uncooled Pyroelectric IR Detectors," <i>Mat. Res. Soc. Symp. Proc.</i> , Vol. 541, pp. 661-666, 1999.					
100	CCQ	Gunapala et al., "Bound-To-Quasi-Bound Quantum-Well Infrared Photodetectors," NASA Tech Brief, Vol. 22, No. 9, September 1998.					
Examiner	•	Herth 2		Date Considered 4/16/02			
*Examiner: Ir	nitial if r		t citation is in conformance with MPEP 60	09; Draw line through citation if not in			

SERIAL NO. ATTY DOCKET NO. U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE orm PT-D 1449 211810US99 09/911,495 (Modified) APPLICANT LIST OF REFERENCES CITED BY APRLICANT BARBARA F. BARENBURG ET AL GROUP FILING DATE FEB U 6 2002 JULY 25, 2001 2813 OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.) Brown that Devices II," Intn. Society for Optical Engineering, Vol. 2999, pp. 211-224. DAA 5/2-Bruley et al., "Nanostructure and Chemistry of a (100)MgO/(100) GaAs Interface," Appl. Phys Lett, 65(5), Aug. 1994, pp. DAB 564-566. 150 Fork et al., "Epitaxial MgO On Si(001) for Y-Ba-Cu-O Thin Film Growth by Pulsed Laser Deposition," Appl. Phys Lett., DAC 58(20), May 20, 1991, pp. 2294-2296. >66 Himpsel et al., "Dialectrics on Semiconductors," Materials Science and Engineering, B1(1988), pp. 9-13. DAD 515/1-Li et al., "Epitaxial La 067Sr_{0.33}MnO₃Magnetic Tunnel Junctions," J. Appl. Phys. 81(8), Apr. 15, 1997, pp. 5509-5511. DAC メムゲ O'Donnell et al., "Colossal Magnetoresistance Magnetic Tunnel Junctions Grown by Molecular-Beam Epitaxy," Appl. DAF Physics Letters, Vol. 76, No. 14, April 3, 2000, pp. 1914-1916. 5B0 Mikami et al., "Formation of Si Epi/MgO-Al₂O₃Epi./SiO₃/Si and Its Epitaxial Film Quality," Fundamental Research DAG Laboratories and Microelectronics Laboratories, pp. 31-34, 1983. 556 T. Asano et al., "An Epitaxial Si/Insulator/Si Structure Prepared by Vacuum Deposition of CaF2 and Silicon," Thin Solid DAH Films, Vol. 93 (1982), pp. 143-150. 5B6-T. Chikyow et al., "Reaction and Regrowth Control of CeO₂ on Si(111) Surface for the Silicon-On-Insulator Structure," Appl. Phys. Lett., Vol. 65, No. 8, 22 August 1994, pp. 1030-1032. SBC DAI J.F. Kang, et al., "Epitaxial Growth of CeO₃(100) Films on Si(100) Substrates by Dual Ion Beams Reactive Sputtering," Solid State Communications, Vol. 108, No. 4, pp. 225-227, 1998. DAJ SOL-R.A. Morgan et al., "Vertical-Cavity Surface-Emitting Lasers Come of Age," SPIE, Vol. 2683, pp. 18-29. DAK 500 Technical Analysis of Qualcomm QCP-800 Portable Cellular Phone (Transmitter Circuitry)," Talus Corporation, Qualcomm DAL QCP-800 Technical Analysis Report, December 10, 1996, pp. 5-8. 5350 Jo-Ey WONG, et al.; "AN ELECTROSTATICALLY-ACTUATED MEMS SWITCH FOR POWER APPLICATIONS"; IEEE, DAM 2000; pp. 633-638 5 G6 T. MIZUNO, et al.; "Electron and Hole Mobility Enhancement in Strained-Si MOSFET's on SiGe-on-Insulator Substrates Fabricated by SIMOX Technology"; IEEE ELÉCTRON DEVICE LETTERS, VOL. 21, NO. 5, MAY 2000; pp. 230-232 DAN 136 F.M. BUFFER, et al.; "Strain-dependence of electron transport in bulk Si and deep-submicron MOSFET's" Computatural DAO Electronics, 2000, Book of Abstracts, IWCE Glasgow 2000, 7th Int'l Workshop on, 2000, pp. 64-65. 5850 S S. LU, et al.; "Piezoelectric field effect transistor (PEFET) using $\ln_{0.2}Ga_{0.8}As/Al_{0.35}Ga_{0.65}As/\ln_{0.2}Ga_{0.8}As/GaAs$ Strained layer structure on (111)B GaAs substrate"; ELECTRONICS LETTERS, 12TH Ma 1994, Vol. 30, No. 10; pp. 823-825 5 BS DAP Kihong KIM, et al." On-Chip Wireless Interconnection with Integrated Antennas"; 2000 IEEE; pp. 20.2.1-20.3.4 DAQ SBG 4/16/22 Examiner Date Considered Examiner: Initial if reference is considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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Form PTO 1449 (Modified)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY DOCKET NO. 211810US99	SERIAL NO. 09/911,495		
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	()	FILING DATE	GROUP		
	FEB 0 6 2002	JULY 25, 2001	2813		
OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, etc.) G. PASSIDIPALIE (V-BAND SINGLE CHIP, DIRECT CARRIER BPSK MODULATION TRANSMITTER WITH					
SGC- EAA					
SPU- EAB	Mau-Chung Frank CHANG, et al.; "RF/Wireless Interconnect for Inter- and Intra-Chip Communications"; Proceedings of IEEE, Vol. 89, No. 4, April 2001; pp. 456-466				
SBG EAC	The Electronics Industry Report, Pris	smark; 2001; pp. 111-120			
SG6 EAD	J.K. ABROKWAH, et al.; "A Manufacturable Complementary GaAs Process"; GaAs IC Symposium, IEEE, 1993; pp. 127-130				
SOC- EAE		ation of the Growth Behaviour of CeO ₂ , Sr	TiO ₃ and SrVO ₃ Films on Si Substrate," <i>Thin</i>		
SBC EAF		Nagata et al., "Heteroepitaxial Growth of CeO ₂ (001) Films on Si(001) Substrates by Pulsed Laser Deposition in Ultrahigh Vacuum," <i>Jpn. Jour. Appl. Phys.</i> , Vol. 30, No. 6B, June 1991, pp. L1136-L1138.			
SBG- EAG	Kado et al., "Heteroepitaxial Growth of SrO Films on Si Substrates," J. Appl. Phys., 61(6), March 15, 1987, pp. 2398-2400.				
SBC EAH	Bean et al., "Silicon Molecular Beam Epitaxy," <i>Materials Research Symposium Proceedings</i> , Vol. 220, pp. 595-600, April 29 - May 3, 1991.				
SCC EAI	J.K. Abrokwah, et al.; "A Manufacturable High-Speed Low-Power Complementary GaAs Process"; Extended Abstracts of the 1994 International Conference on Solid State Devices and Materials, Yokohama, 1994, pp.592-594				
SOC- EAJ	Leonard J. BRILLSON; "Stable and Epitaxial Contacts to III-V Compound Semiconductors"; Semiconductors Fundamentals and Technology; Noyles Publications, 1993; pp.67-150				
573 L- EAK	Jayshri SABARINATHAN et al.; "Submicron three-dimensional infrared GaAs/Al,O _y -based photonic crystal using single-step epitaxial growth"; APPLIED PHYSICS LETTERS, VOLUME 78, NUMBER 20, 14 MAY 2001; pp.3024-3026				
586 EAL	Philip BALL; "The Next Generation of Optical Fibert"; Technology Review, May 2001; pp.55-61				
536- EAM	John D. JOANNOPOULOS, et al.; "Molding the Flow of Light"; Photonic Crystals; Princeton University Press, 1995				
SBC- EAN	Thomas F. KRAUSS, et al.; "Photon Electronics 23 (1999) 51-96	ic crystals in the optical regime - past, pro	esent and future"; Progress in Quantum		
SBC- EAO	G. H. JIN, et al.; "PLZT Film Waveguide Mach-Zehnder Electrooptic Modulator"; Journal of Lightwave Technology, Vol. 18, No. 6. June 2000; pp.807-812				
SBC- EEP	D.E. ASPNES, et al.; "Steps on (00"	1) silicon surfaces"; J. Vac. Sci. Technol.	B, Vol. 5, No. 4, Jul/Aug 1987; pp. 939-944		
SBU EAG		n field effect transistor"; APPLIED PHYSIC	CS LETTERS, VOLUME 73, NUMBER 6, 10		
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Form PTO 1449 (Modified)	6)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY DOCKET NO. 211810US99	SERIAL NO. 09/911,495			
APPLICANT BARBARA F. BARENBURG ET AL							
		FES 0 6 2002	JULY 28, 2001	2813			
	OTHER REPERENCES (Including Author, Title, Date, Pertinent Pages, etc.)						
506	FAA	Lucent Technologies, Inc. "Arrayed V	Vaveguide Grating Multiplexer/Demultiple	exer"; January 2000; 4 pages			
500	FAB	Hisashi SHICHIJO, et al.; "Co-Integration of GaAs MESFET and Si CMOS Circuits"; IEEE ELECTRON DEVICE LETTERS, VOL. 9, NO. 9, SEPTEMBER 1988; pp.444-446					
SEG	FAC	H. SHICHIJO, et al.; "GaAs MESFET Symposium - 239-242	and Si CMOS Cointegration and Circuit	Techniques"; 1988 IEEE; GaAs IC			
530	FAD	H. SHICHIJO, et al.; "Monolithic Process for Co-Integration of GaAs and Silicon Circuits"; 1988 IEEE; pp.778-781					
SBV	FAE		nulti-quantum wells at 1.3, m wavelength NUMBER 20, 18 MAY 1998; pp.2598-260	on GaAs compliant substrates"; APPLIED 00			
100-	FAF		rphic InAlAs/InGaAs Enhancement Mode L. 20, NO. 10, OCTOBER 1999; pp.507-				
166	FAC	Tomonori NAGASHIMA, et al.; "Three-Terminal Tandem Solar Cells With a Back-Contact Type Bottom Cell" Higashifuji Technical Center, Toyota Motor Corporation; 4 pages					
\$ BC	FAH	James SCHELLENBERG, et al.; "Low-Loss, Planar Monolithic Baluns for K/Ka-Band Applications"; 1999 IEEE MTT-S Digest; pp.1733-1736					
536	FAI	Patent Abstracts of Japan, Vol. 010, No. 289, October 2, 1986 & JP 61 108187, May 26, 1986					
500	FAJ	Patent Abstracts of Japan, Vol. 017,	No. 344 & JP 05 048072, February 26, 1	993			
506	FAK	Patent Abstracts of Japan, Vol. 1999	, No. 14, December 22, 1999 & JP 11 26	60835, September 24, 1999			
586	FAL	Patent Abstracts of Japan, Vol. 012,	No. 388, October 17, 1988 & JP 63 131	104, June 3, 1988			
5 (GC)	FAM	Patent Abstracts of Japan, Vol. 012, No. 246, July 12, 1988 & JP 63 034994, February 15, 1988 FAM					
130	FAN	Patent Abstracts of Japan, Vol. 012, No. 077, March 10, 1988 & JP 62 216600, September 24, 1987 FAN					
500	FAO	R.D. VISPUTE; "High quality optoele Thin Solid Films 299 (1997), pp.94-1	ctronic grade epitaxial AIN films on α-Alg 03	$_2$ 0 $_3$, Si and 6H-SiC by pulsed laser deposition";			
336	FAP	T. Warren WEEKS, et al.; "GaN thin temperature monocrystalline AIN buf	films deposited via organometallic vapor fer layers" 320 Applied Physics Letters,	phase epitaxy on α (6H)-SiC(0001) using high-Vol. 67, No. 3, 17 July 1995, ppl401-403			
566	FAQ	Z. YU, et al.; "Epitaxial oxide thin film	ns on SI(001)*"; J. Vac. Sci. Technol. B. \	Vol. 18, No. 4, Jul/Aug 2000; pp.2139-2145			
Examiner		1-166		Date Considered 4/16/0 -			
*Examiner: Ir	nitial if r	eference is considered, whether or no of considered. Include copy of this form	t citation is in conformance with MPEP 6 with next communication to applicant.	09; Draw line through citation if not in			

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Form PTO 1449 (Modified)	•	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	211810US99	SERIAL NO. 09/911,495		
LIST OF	LIST OF REFERENCES CITED BY APPLICANT BARBARA F BARENBURG ET AL					
FEB 0 6 2002 FILING DATE GROUP 2813						
		OTHER REPERENCES (Including Author, Title, Date, Pertinent			
-500	НАА		O ₃ Films on Si(100) Substrates Using a Fo	cused Electron Beam Evaporation Method,"		
430	НАВ		Moon et al., "Growth of Crystalline SrTiO ₃ Films on Si Substrates Using Thin Fluoride Buffer Layers and Their Electrical Properties," <i>Jpn. J. of Appl. Phys.</i> , Vol. 33, (1994), pp. 5911-5916.			
500 560	HAC	Farrow et al., "Heteroepitaxy of Dissi - May 2, 1991.	Farrow et al., "Heteroepitaxy of Dissimilar Materials," Mat. Res. Soc. Symposium Proceedings, Vol. 221, pp. 29-34, April 29 - May 2, 1991.			
500	HAD	Choi et al., "Heteroepitaxy on Silicon: Fundamentals, Structure, and Devices," <i>Mat. Res. Soc.</i> , Symposium Proceedings, Vol. 116, pp. 369-374, April 5-8, 1988.				
166	HAE	Douglas B. Chrisey, et al; Pulsed Las	ser Deposition of Thin Films; pp. 273-285			
536	HAF	B.A. Block, et al; "Photoluminescenc 25-27	e properties of Er ³ -doped BaTiO ₃ thin films	s"; Appl. Phys. Lett. 65 (1), 4 July 1994, pp.		
586	HAG	Gentex Corporate Website; "Photoelectric Smoke Detectors - How They Work; 2001				
500-	НАН	Jeffrey B. Casady, et al.; "A Hybrid 6H-SiC Temperature Sensor Operational from 25° C to 500° C"; IEEE TRANSACTIONS ON COMPONENTS, PACKAGING, AND MANUFACTURING TECHNOLOGY - PART A, VOL. 19, NO. 3, SEPTEMBER 1996; pp. 416-422				
556-	HAI	Ronald W. WAYNANT, et al.; "OPTO McGraw-Hill, Inc., 1994; Chapter Tw	DELECTRONIC INTEGRATED CIRCUITS' enty Seven	"; ELECTRO-OPTICS HANDBOOK,		
Ì	HAJ					
	HAK					
	HAL					
	НАМ					
	HAN					
	НАО					
	НАР					
	HAQ					
Examiner		106 9		Date Considered 4/16/00		
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